

METHOD AND APPARATUS FOR MAINTAINING MASK STRAND SPATIAL UNIFORMITY

5 This invention generally relates to color picture tubes and, more particularly, a method and apparatus for fabricating tension masks for color picture tubes.

BACKGROUND OF THE INVENTION

10

A color picture tube includes an electron gun for forming and directing three electron beams to a screen of the tube. The screen is located on the inner surface of the faceplate of the tube and is made up of an array of
15 elements of three different color emitting phosphors. An aperture mask, which may be either a domed mask or a tension mask, is interposed between the gun and the screen to permit each electron beam to strike only the phosphor elements associated with that beam. A mask is a thin sheet
20 of metal, such as steel, that is contoured to somewhat parallel the inner surface of the tube faceplate. A focus mask comprises two sets of conductive lines that are perpendicular to each other and separated by an insulator. When different potentials are applied to the two sets of
25 lines to create multiple focusing lenses in each of the mask openings, the mask is referred to as a focus mask. One type of focus mask is a tension focus mask, wherein at least one of the sets of conductive lines is under tension. Generally, in a tension focus mask, a vertical set of
30 conductive lines or strands is under tension and a horizontal set of conductive lines or wires overlies the strands.

In assembling a strand tension mask, it is required to assemble the strands with a high degree of accuracy to
35 achieve consistent spacing between the strands.

SUMMARY OF THE INVENTION

5 The present invention provides a method and apparatus
for maintaining uniform spacing between the strands of a
tension mask. The apparatus includes providing a set of
barrier ridges and affixing them to a tension mask. The
barrier ridge is aligned perpendicular to the strands of
10 the tension mask and affixed to the frame near the ends of
the tension mask. The barrier ridges traverse the length
of the tension mask and act to keep the mask strands
parallel and equidistantly spaced from each other when
faced with applied stress during mask welding and
subsequent thermal processing. After the barrier ridges
15 are affixed to the frame, the tension mask is mounted to
the mask frame. The barrier ridges are affixed to the
frame inside the frame and directly under and in contact
with the mask strands. When the tension mask is mounted to
the mask frame, the barrier ridges lay inside the mask
20 frame, and between the mask frame and the array region of
the tension mask that produces visible image on the screen.
The mask strands are in frictional contact with the barrier
ridge. They may also be adhered to the ridge by a suitable
adhesive such as Kasil.

25 During mask-to-frame welding, mask strands are welded
directly to the cantilever of the frame. Because of the
frictional force exerted by the barrier ridge, mechanical
stresses applied to strands along the weld contact points
are isolated to the regions of the strands of the contact
30 points. Therefore, the portions of the strands between the
barrier ridges are, advantageously, less affected by the
mechanical stresses and maintain their positions. After
the tension mask is affixed to the mask frame, the entire
mask frame assembly is used in manufacturing a color
35 picture tube. As such, the assembly is processed through a
series of thermal cycles. The barrier ridges expand and
contract in unison with the mask frame. By attaching the

tension mask strands to the barrier ridges, spatial integrity between the strands is thus maintained during the manufacturing of the strand tension masks, subsequent processing and tube operation.

5

BRIEF DESCRIPTION OF THE DRAWINGS

FIG. 1 is a side view, partially in the axial section, of a color picture tube, including a strand tension focus mask-frame-assembly according to the present invention;

FIG. 2 is a perspective view of the strand tension focus mask-frame-assembly of FIG. 1;

FIG. 3 is a front view of a tension mask frame of FIG. 2 prior to attachment of the strand tension mask;

FIG. 4 is a front view of the strand tension mask of FIG. 2 prior to welding to the tension mask frame;

FIG. 5 is a front view of a tension mask of FIG. 4 depicting the locations of the tension mask which will contact the barrier ridges on the mask frame; and

FIG. 6 is a front view of the tension mask assembly according to the present invention; this drawing illustrates the relationship between the locations of the mask frame, the barrier ridges and the mask skirt.

25

DETAILED DESCRIPTION

FIG. 1 shows a cathode ray tube 10 having a glass envelope 12 comprises a rectangular faceplate panel 14 and a tubular neck 16 connected by a rectangular funnel 18. The funnel 18 has an internal conductive coating (not shown) that extends from an anode button 20 to a neck 16. The panel 14 comprises a viewing faceplate 22 and a peripheral flange or sidewall 24 that is sealed to the funnel 18 by a glass sealing frit 26. A three-color phosphor screen 28 is carried by the inner surface of the faceplate 22. The screen 28 is a line screen with the phosphor lines arranged in triads, each triad including a

092720 0222860

phosphor line of each of the three colors. A cylindrical tension mask 30 is removably mounted in a predetermined spaced relation to the screen 28. The mask may be either a tension focus mask or a tension mask. An electron gun 32 (schematically shown by the dashed lines in FIG. 1) is centrally mounted within the neck 16 to generate three in-line electron beams, a center beam and two side beams, along convergent paths through the mask 30 to the screen 28.

The tube 10 is designed to be used with an external magnetic deflection yoke, such as the yoke 34 shown in the neighborhood of the funnel to neck junction. When activated, the yoke 34 subjects the three beams to magnetic fields that cause the beams to scan horizontally and vertically in a rectangular raster over the screen 28.

A strand tension focus mask 30, shown in greater detail in FIG. 2, includes two long sides 36 and 38 and two short sides 40 and 42. The two long sides 36 and 38 of the mask parallel a central major axis, x , of the tube. The tension mask 30 includes two sets of conductive lines: strands 44 that are parallel to the central minor axis y and to each other; and crosswires 46, that are parallel to the central major axis x and to each other. The crosswires 46 are coupled to busbars (not shown) on their distal ends and lie above the mask strands. In one embodiment, the strands 44 are flat strips that extend vertically, having a width of about 13 mils and a thickness of about 2 mils, and the crosswires 46 have a round cross section, having a diameter of approximately 1 mil and extend horizontally. In the completed mask, the strands and crosswires 46 are separated from each other by a suitable insulator such as lead frit.

FIG. 3 is a front view of a mask frame 300 similar to that of FIG. 2. The mask frame 300 is comprised of a set of segments attached together to form a generally rectangular shape. Segments 302 and 304 represent the vertical elements of the mask frame 300. The mask frame

100-000000-000000

300 also includes horizontal segments 306 and 308. Element 310 is a representation of an aperture formed inside the mask frame 300. Cantilevers 312A and 312B are outer portions of the mask frame 300. These cantilevers 312A and 312B are the areas to which strands 44 of stand alone tension mask 400 of Figure 4 are welded. Barrier ridges 313A and 313B shown in Figure 3, are attached to the mask frame 300 and help to make up part of the horizontal segments 306 and 308. FIG. 6 represents how a tension mask 400 is generally affixed to a mask frame 300.

FIG. 4 is a front view of the stand alone tension mask 400 that is used, when assembled, in the arrangement of FIG. 2. The free tension mask 400 is formed of a flat thin sheet of material that has been etched to form a plurality of strands 44 between two edge portions 404A and 404B. Edges 404A and 404B are used for handling purposes prior to mask frame welding and are removed or severed afterward. FIG. 5 is a front view of the tension mask 400 of FIG. 4, depicting the locations of attachment points 402A and 402B of the free tension mask 400 which will be in frictional contact with the barrier ridges 313A and 313B. The barrier ridge elements 313A and 313B are aligned (as discussed below) generally perpendicularly to the mask strands 44. Next, FIG. 6 is a front view of the tension mask assembly according to the present invention; this drawing illustrates the relationship between the locations of the mask frame 300, the barrier ridge elements 313A and 313B, the mask edge portions 404A and 404B and the locations of attachment points 402A and 402B prior to severing the borders 404A and 404B.

To best understand the invention, the reader should simultaneously refer to FIGS. 3, 4, 5 and 6. The mask aperture area, or viewable array region, 406 in which the mask strands 44 traverse, is an area in which it is essential for mask strands 44 to maintain proper spatial integrity in relation to the mask frame 300 during assembly of the mask frame assembly 30 and the picture tube 10. If

proper spatial integrity is not maintained between the individual mask strands 44 and the mask frame 300, the electron beam is caused to misregister, relative to its intended phosphor target, thus creating a visible optical anomaly on the phosphor screen 28, typically affecting color purity or causing visible streaks. It is therefore desirable to maintain parallel and uniform spacing between the mask strands 44. Commonly used mask frame 300 materials include but are not limited to steel alloys or iron-nickel alloys.

As mentioned above, the free tension mask 400 is formed of a flat thin sheet of material that has been etched to form a plurality of strands 44 between two edge portions 404. Each strand 44 is substantially parallel to the other, and each strand 44 is spaced at a precise distance apart from the other. The material of the free tension mask 400 is formed of is generally a steel or an iron nickel alloy.

Direct welding of each of mask strands 44 to the cantilevers 312A and 312B is necessary in that it allows each individual mask strand 44 to be isolated from the other mask strands 44 during tube fabrication and operation. The barrier ridges 313A and 313B to which the mask strands 44 are in frictional contact isolate each mask strand 44 from other mask strands 44 during the welding of the mask strands 44 to the cantilevers 312A and 312B.

FIG. 5 is a rear view of the tension mask 400 of FIG. 4, depicting the locations of attachment points 402A and 402B of the free tension mask 400 barrier ridges 313A and 313B of the present invention. The mask strands 44 are attached perpendicularly to the barrier ridges 313A and 313B as mentioned above. The barrier ridges are mechanical components of the mask frame 300. The barrier ridges 313A and 313B as well as the cantilevers 312A and 312B have accurate contours.

The barrier ridges 313A and 313B to which the mask strands 44 contact prevent the mask strands in the area of

the barrier ridges 313A and 313B from losing spatial integrity in relation to each other and to the mask frame 300. The friction between mask strands 44 and barrier ridge 313A or 313B prohibits mask strands 44 from moving laterally, during the welding process of mask strands 44 to cantilever 312A or 312B, respectively. Strands 44 may be added to barrier ridges 313A and 313B using suitable adhesive such as Silicate glass for further prohibiting the lateral movement of strands 44.

FIG. 6 is a top view of the tension mask assembly 30 according to the present invention; this drawing illustrates the relationship between the locations of the mask frame 300, the barrier ridges 313A and 313B and the mask edge portions 404A and 404B. The free tension mask 400 is inserted into, and placed under tension, by a stretching fixture (not shown). The tension created by the stretching fixture maintains the spatial integrity of the mask strands 44. The tension mask 400 is then laid across and brought into contact with the mask frame 300. At this point, the locations or attachment points 402A and 402B of the free tension mask 400 contact the barrier ridges 313A and 313B.

The strands 44 are then attached to the cantilevers 312A and 312B by welding or other attachment method. The method of welding the strands 44 to the mask frame 300 is accomplished by, but not limited to, seam, resistance, spot, laser, and tack welding. After the mask strands 44 have been affixed to the cantilevers 312A and 312B, the entire mask frame assembly 30 is prepared for further processing.

As the embodiments that incorporate the teachings of the present invention have been shown and described in detail, those skilled in the art can readily devise many other varied embodiments that still incorporate these teachings without departing from the spirit of the invention.